

Docket No.: 245637US0

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ATTORNEYS AT LAW

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

RE: Application Serial No.: 10/716,427

Applicants: Takashi TATSUMI, et al.

Filing Date: November 20, 2003

For: MESOPOROUS SILICA AND PROCESS FOR

PRODUCING THE SAME

Group Art Unit: 1621

Examiner: NAGUBANDI, L.

SIR:

Attached hereto for filing are the following papers:

## Request for Extension of Time (One Month) Request for Reconsideration Copy of Gao, et al.

Our credit card payment form in the amount of \$120.00 is attached covering any required fees. In the event any variance exists between the amount enclosed and the Patent Office charges for filing the above-noted documents, including any fees required under 37 C.F.R 1.136 for any necessary Extension of Time to make the filing of the attached documents timely, please charge or credit the difference to our Deposit Account No. 15-0030. Further, if these papers are not considered timely filed, then a petition is hereby made under 37 C.F.R. 1.136 for the necessary extension of time. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

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